#### Semiconductors: A general introduction

Classification of Materials in terms of electrical resistivity:

| Insulators | $10^{10}$ – | $10^{18}$ | $\Omega$ cm |
|------------|-------------|-----------|-------------|
|            |             |           |             |

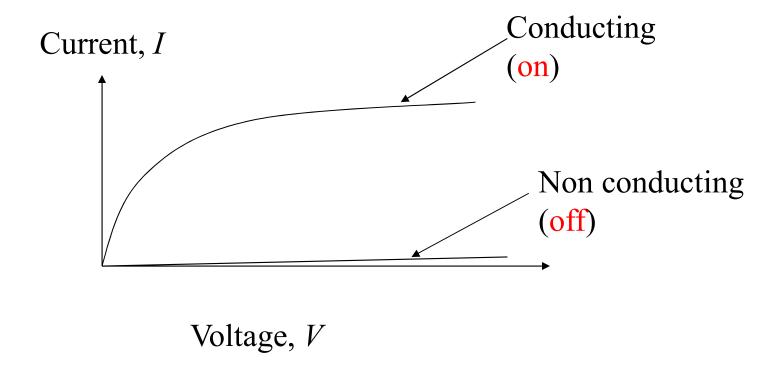
Semiconductors 
$$10^{-4} - 10^8 \Omega \text{ cm}$$

Conductors 
$$10^{-6} - 10^{-4} \Omega \text{ cm}$$

The uniqueness of semiconductors is that their conductivity can be varied **by us** over a wide range, e.g. by

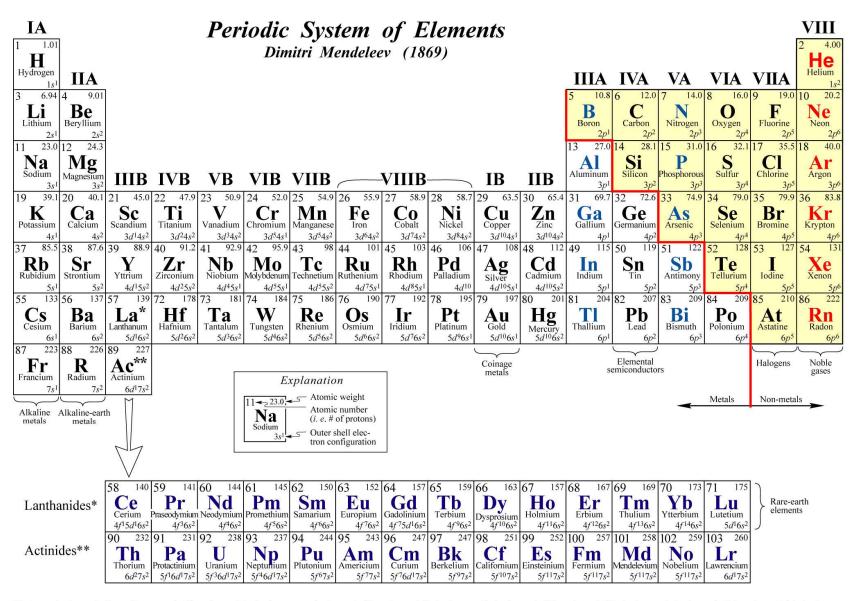
- adding minute quantities of impurities
- by applying electric field
- illumination

#### **Introduction**



We can use this as a switch. (Example: Digital computers)

#### Periodic table of the elements



**Note**: s-electron shell can be occupied by at most 2 electrons; p-electron shell by at most 6 electrons; d-electron shell by at most 10 electrons; f-electron shell by at most 14 electrons; Noble gases have 2 (He), 10 (Ne), 18 (Ar), 36 (Kr), 54 (Xe), and 86 (Rn) electrons

### Abbreviated periodic table of the elements

| 4  | 5  | 6  | 7  | 8  |
|----|----|----|----|----|
| Be | В  | C  | N  | О  |
| 12 | 13 | 14 | 15 | 16 |
| Mg | Al | Si | P  | S  |
| 30 | 31 | 32 | 33 | 34 |
| Zn | Ga | Ge | As | Se |
| 48 | 49 | 50 | 51 | 52 |
| Cd | In | Sn | Sb | Te |
| 80 | 81 | 82 | 83 | 84 |
| Hg | T1 | Pb | Bi | Po |

$$\frac{\text{Elements}}{E_{\text{Si}}} = 1.1 \text{ eV}$$
$$E_{\text{Ge}} = 0.67 \text{eV}$$

#### Compounds

$$\overline{E_{\text{GaAs}}} = 1.43 \text{eV}$$
 $E_{\text{GaSb}} = 0.7 \text{eV}$ 
 $E_{\text{GaN}} = 3.4 \text{eV}$ 

The most common semiconductor is **Silicon** 

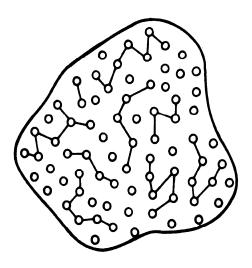
#### Semiconductor materials

 Table 1.1
 Semiconductor Materials.

| General          | Semiconductor  |  |  |
|------------------|--|--|--|
| Classification   | Symbol   | Name                                       |  |
| (1) Elemental    | Si   | Silicon                                    |  |
|                  | Ge   | Germanium                                  |  |
| (2) Compounds    |  |  |  |
| (a) IV-IV        | SiC  | Silicon carbide                            |  |
| (b) III-V        | AlP  | Aluminum phosphide                         |  |
|                  | AlAs   | Aluminum arsenide                          |  |
|                  | AlSb   | Aluminum antimonic                         |  |
|                  | GaN  | Gallium nitride                            |  |
|                  | GaP  | Gallium phosphide                          |  |
|                  | GaAs   | Gallium arsenide                           |  |
|                  | GaSb   | Gallium antimonide                         |  |
|                  | InP  | Indium phosphide                           |  |
|                  | InAs   | Indium arsenide                            |  |
|                  | InSb   | Indium antimonide                          |  |
| (c) II-VI        | ZnO  | Zinc oxide                                 |  |
| (-,              | ZnS  | Zinc sulfide                               |  |
|                  | ZnSe   | Zinc selenide                              |  |
|                  | ZnTe   | Zinc telluride                             |  |
|                  | CdS  | Cadmium sulfide                            |  |
|                  | CdSe   | Cadmium selenide                           |  |
|                  | CdTe   | Cadmium telluride                          |  |
|                  | HgS  | Mercury sulfide                            |  |
| (d) IV-VI        | <del>-</del>   | Lead sulfide                               |  |
| (d) 1 v = v 1    | PbSe   | Lead selenide                              |  |
|                  | PbTe   | Lead telluride                             |  |
| (3) Alloys       |  |  |  |
| (a) Binary       | Si, "Ge"   |  |  |
| •                | Al <sub>x</sub> Ga <sub>1-x</sub> As                 | (or $Ga_{l-x}Al_xAs$ )                     |  |
| (b) Termary      | $Al_x In_{1-x} As$                                   | $(\text{or } In_{1-x}Al_xAs)$              |  |
|                  | $Cd_{1-x}Mn_xTe$                                     | $(OI III_{l-x}/II_x/IS)$                   |  |
|                  |  |  |  |
|                  | $GaAs_{1-x}P_x$                                      | (I- C- A)                                  |  |
|                  | $Ga_x In_{1-x}As$                                    | $(\text{or In}_{1-x}\text{Ga}_x\text{As})$ |  |
|                  | $Ga_x In_{1-x} P$<br>$Hg_{1-x} Cd_x Te$              | $(\text{or In}_{1-x}\text{Ga}_x\text{P})$  |  |
| (c) Quaternary . | Al <sub>x</sub> Ga <sub>1-x</sub> As <sub>y</sub> St | $o_{1-v}$                                  |  |
| . , -            | $Ga_{x}In_{1-x}As_{1-y}$                             |  |  |

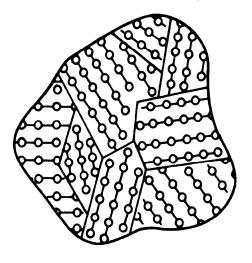
#### Crystalline solids

The fact that one can alter the properties of semiconductors over a wide range may have something to do with the atomic arrangement of atoms in these materials. So, let us look at the crystal structure.



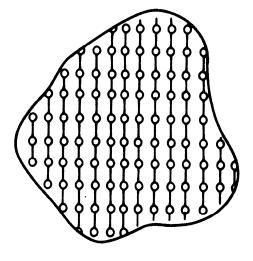
(a) Amorphous

No recognizable long-range order



(b) Polycrystalline

Completely ordered in segments



(c) Crystalline

Entire solid is made up of atoms in an orderly array

Figure 1.1

#### Crystalline solids

<u>Lattice</u>: Periodic arrangement of atoms. The atomic arrangement determines the macro-properties of the crystal.

#### Examples:

- Amorphous Si thin film transistors used as switching devices in LCDs
- Polycrystalline Si used as gate in MOSFETs
- Actual active region of MOSFET is fabricated in crystalline Si

#### Unit cell concept

The *unit cell* is a small portion of any given crystal that could be used to reproduce a crystal.

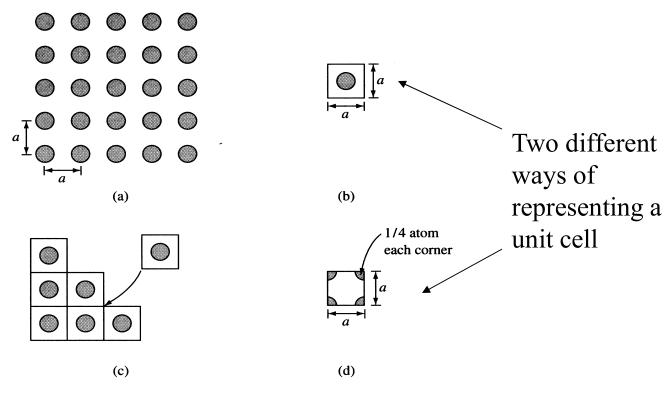
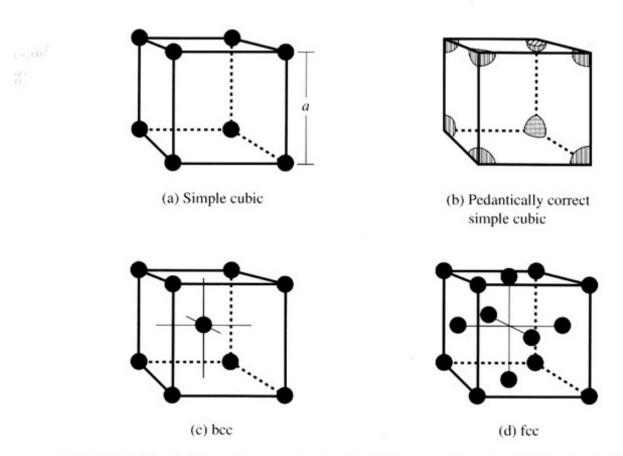


Figure 1.2

#### Simple 3D unit cells



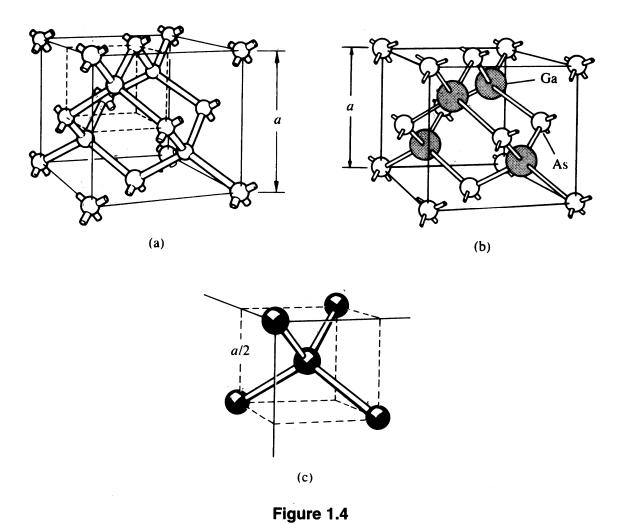
**Figure 1.3** Simple three-dimensional unit cells. (a) Simple cubic unit cell. (b) Pedantically correct simple cubic unit cell including only the fractional portion (1/8) of each corner atom actually within the cell cube. (c) Body centered cubic unit cell. (d) Face centered cubic unit cell.

# Crystal structure of Si and Ge and other common semiconductors

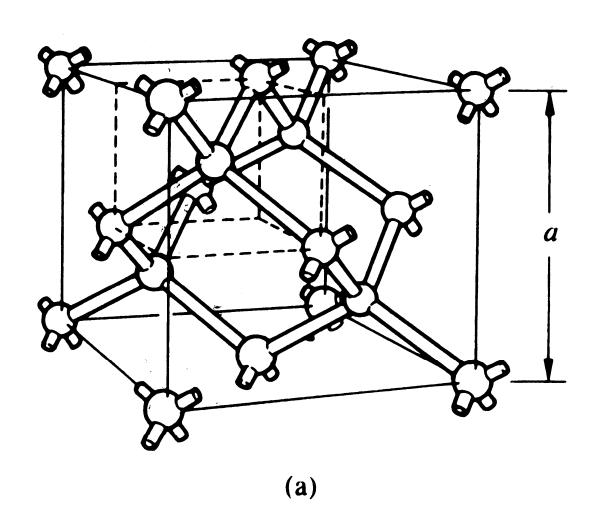
- 2 FCC lattices displaced by ((1/4) a, (1/4) a, (1/4) a) along body diagonal\*
- 8 atoms per unit cell
- Diamond lattice (also called "zincblende" if interpenetrating FCC lattices are made of different elements like in GaAs)
- Each atom is bonded to 4 other atoms (tetrahedral bonding structure)

\* The lattice constant or cubic edge is "a". Generally a is expressed in Angstroms. 1  $Å = 10^{-8}$  cm =  $10^{-10}$  m

#### Diamond and zincblende lattice unit cells



## Diamond lattice (detail)



#### **Example**

What is the number of Si atoms in 1 cm<sup>3</sup> of Si?

Given is the lattice constant: a = 5.43 Å

$$\frac{8 \text{ atoms}}{a^3} = 5 \times 10^{22} \frac{\text{atoms}}{\text{cm}^3}$$

What is the density of Si?

Atomic weight of Si = 28.1 i.e. 1 mole ( $N_A$  = 6.023 x 10<sup>23</sup> atoms) of Si has a mass of 28.1 g

Density = 
$$\frac{5 \times 10^{22} \frac{\text{atoms}}{\text{cm}^3} \times 28.1 \frac{\text{gm}}{\text{mole}}}{6.02 \times 10^{23} \frac{\text{atoms}}{\text{mole}}} = 2.33 \frac{\text{g}}{\text{cm}^3}$$